	Application No.	Applicant(s)	
Notice of Allowability	10/752,210	10/752,210 BAE, MYOUNG-KWANG	
	Examiner	Art Unit	,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,
	Tu-Tu Ho	2818	pr
The MAILING DATE of this communication ap All claims being allowable, PROSECUTION ON THE MERITS I herewith (or previously mailed), a Notice of Allowance (PTOL-8 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT of the Office or upon petition by the applicant. See 37 CFR 1.3	S (OR REMAINS) CLOSED i 5) or other appropriate comm RIGHTS. This application is 13 and MPEP 1308.	n this application. If not include unication will be mailed in due o	d course. THIS
This communication is responsive to <u>Papers filed on 06/3</u> —	<u>30/2004</u> .		
2. 🛮 The allowed claim(s) is/are <u>1-16</u> .			
3. $igotimes$ The drawings filed on <u>06 January 2004</u> are accepted by	the Examiner.		
 4. Acknowledgment is made of a claim for foreign priority a) All b) Some* c) None none none 1. Certified copies of the priority documents hat 2. Certified copies of the priority documents hat 3. Copies of the certified copies of the priority of International Bureau (PCT Rule 17.2(a)). * Certified copies not received: 	ive been received. Ive been received in Applicati	on No. <u>10/364,942</u> .	ion from the
Applicant has THREE MONTHS FROM THE "MAILING DATE noted below. Failure to timely comply will result in ABANDON THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		e a reply complying with the req	uirements
 A SUBSTITUTE OATH OR DECLARATION must be sub INFORMAL PATENT APPLICATION (PTO-152) which g 			OTICE OF
6. CORRECTED DRAWINGS (as "replacement sheets") m (a) including changes required by the Notice of Draftsper 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examine Paper No./Mail Date Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR each sheet. Replacement sheet(s) should be labeled as such in	erson's Patent Drawing Revie er's Amendment / Comment o	or in the Office action of the drawings in the front (not the	back) of
 DEPOSIT OF and/or INFORMATION about the department department regarding REQUIREMEN 	DOSIT OF BIOLOGICAL MAT IT FOR THE DEPOSIT OF BI	ERIAL must be submitted. N OLOGICAL MATERIAL.	lote the
 Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☑ Information Disclosure Statements (PTO-1449 or PTO/Staper No./Mail Date 01/06/2004) 4. ☐ Examiner's Comment Regarding Requirement for Deposition of Biological Material 	3) 6. ☐ Interview S Paper No B/08), 7. ☒ Examiner's	nformal Patent Application (PTC Summary (PTO-413), ./Mail Date s Amendment/Comment s Statement of Reasons for Allow	·
	David Nelms risory Patent Examiner nnology Center 2800		

U.S. Patent and Trademark Office PTOL-37 (Rev. 1-04) Art Unit: 2818

DETAILED ACTION

Election/Restrictions

1. Claim 1 is generic and allowable. Accordingly, the restriction requirement as to the encompassed species is hereby withdrawn and claims 2-5, directed to the species of Fig. 3K, no longer withdrawn from consideration since all of the claims to this species depend from or otherwise include each of the limitations of an allowed generic claim.

In view of the above noted withdrawal of the restriction requirement as to the linked species, applicant(s) are advised that if any claim(s) depending from or including all the limitations of the allowable generic linking claim(s) be presented in a continuation or divisional application, such claims may be subject to provisional statutory and/or nonstatutory double patenting rejections over the claims of the instant application. Once a restriction requirement is withdrawn, the provisions of 35 U.S.C. 121 are no longer applicable. See *In re Ziegler*, 44 F.2d 1211, 1215, 170 USPQ 129, 131-32 (CCPA 1971). See also MPEP § 804.01.

Allowable Subject Matter

2. Claims 1-16 are allowable over the prior art of record.

The following is an examiner's statement of reasons for allowance: The prior art of record fails to teach or render obvious a fuse box of an integrated circuit device having all exclusive limitations as recited in claims 1, 9, and 16, comprising a fuse line at a fuse portion, a first insulating layer on the fuse line, a first guard ring pattern enclosing the fuse line and on the first insulating layer, a second insulating layer on the first guard ring pattern and the first insulating layer, and a second guard ring pattern that encloses the fuse line on the second insulating layer, characterized in that a passivation layer, on the second insulating layer and the second guard ring pattern, defines a portion of a fuse opening having a sidewall in the first and second insulating layers and the passivation layer extends on the sidewall of the fuse opening to at least the first

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insulating layer, or that the second insulating layer has an opening partially exposing the fuse

portion and the first guard ring pattern.

Any comments considered necessary by applicant must be submitted no later than the

payment of the issue fee and, to avoid processing delays, should preferably accompany the issue

fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for

Allowance."

Conclusion

3. The prior art made of record and not relied upon is considered pertinent to applicant's

disclosure. Copies of the references are not being furnished with this Office Action per MPEP

§ 707.05(a).

U.S. Patent 6,121,073 to Huang et al., cited in the parent application, discloses a fuse

structure for integrated circuit having a fuse portion comprising multiple-level metal patterns,

which do not appear to form a ring, and a passivation layer, which together with the multiple-

level metal patterns forms a fuse opening, over a fuse line, the passivation layer not extending on

the sidewall of the fuse opening to at least a lower interlevel dielectric layer, and an upper

interlevel dielectric layer not partially exposing the fuse portion and not partially exposing a

lower metal pattern of the multiple-level metal patterns.

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4. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tu-Tu Ho whose telephone number is (571) 272-1778. The examiner can normally be reached on 6:30 am - 5:00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, DAVID NELMS can be reached on (571) 272-1787. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Tu-Tu Ho July 14, 2004

David Nelms
Supervisory Patent Examiner
Technology Center 2800